

FEB 25 2008

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Heng Liu  
Assignee: BridgeLux, Inc.  
Title: Chemical Vapor Deposition Reactor  
Application No.: 10/727,746 Filing Date: December 3, 2003  
Examiner: Ram N. Kackar Group Art Unit: 1763  
Docket No.: M-15626-1D US Confirmation No.: 8880

Irvine, California  
February 25, 2008

Via Facsimile to (571) 273-8300

Mail Stop AMENDMENT  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**PETITION FOR EXTENSION OF TIME**

Dear Sir:

Applicants respectfully petition for a TWO-month extension of time within which to respond to the Office Action mailed September 24, 2007, such extension allowing Applicants until Monday, February 25, 2008 to respond.

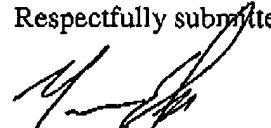
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I hereby certify that this paper is being facsimile transmitted to the U.S. Patent and Trademark Office on the date shown below.

  
Monique M. Butler

February 25, 2008  
Date of Signature

Respectfully submitted,

  
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Page 1 of 1